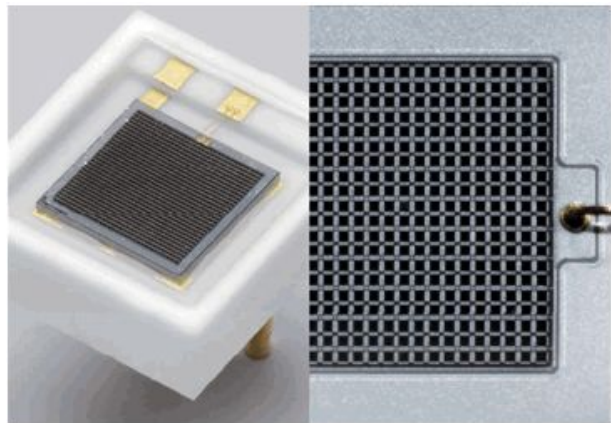


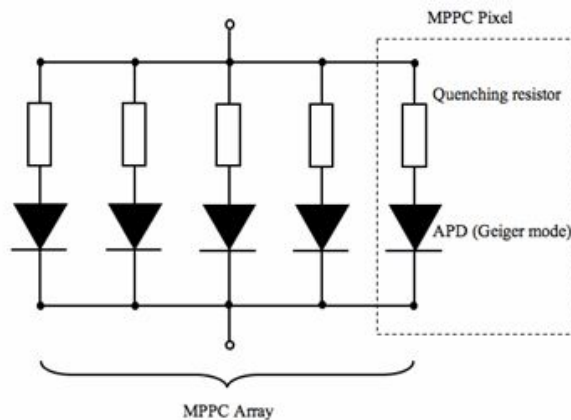
WL Summer Symposium Presentation

Darya Dayanim

Silicon Photomultipliers (SiPMs)

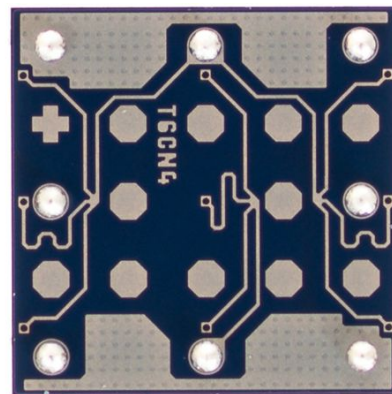
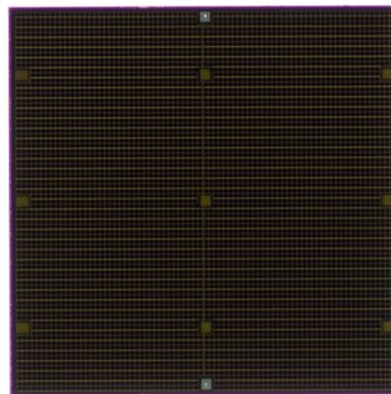


From Hamamatsu

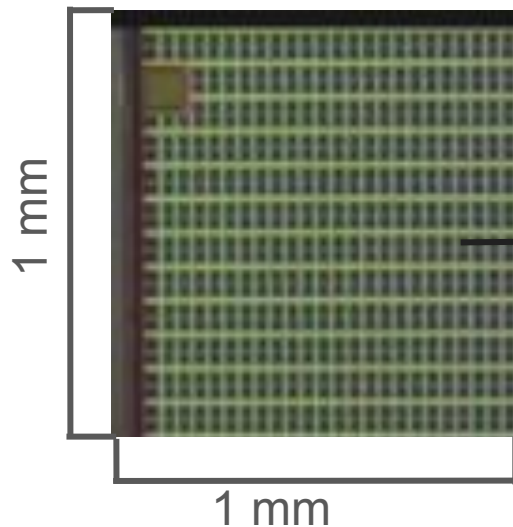


- Increased usage in physics experiments
- Pixels and their reset times

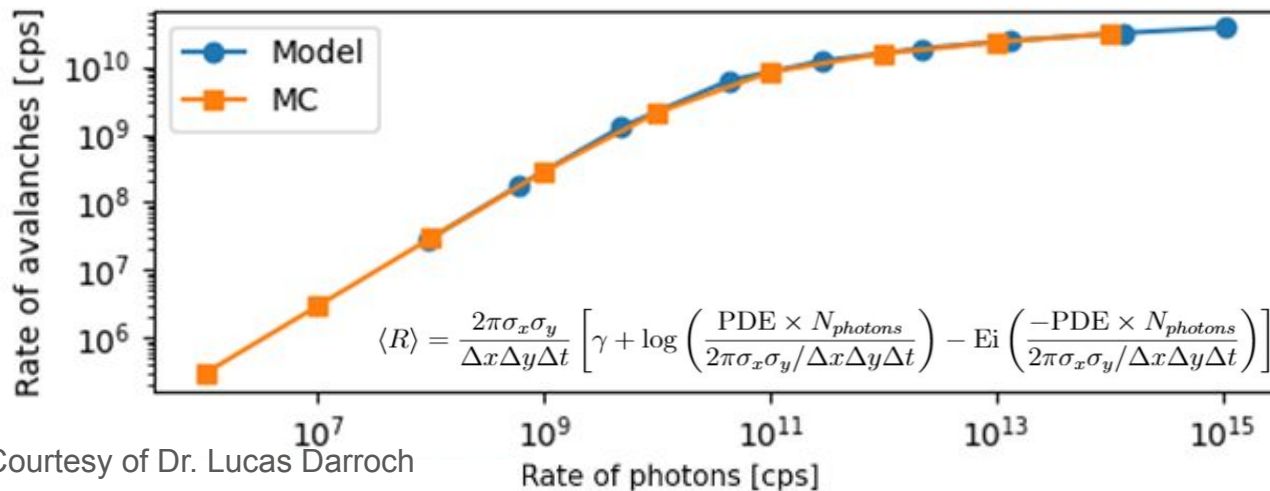
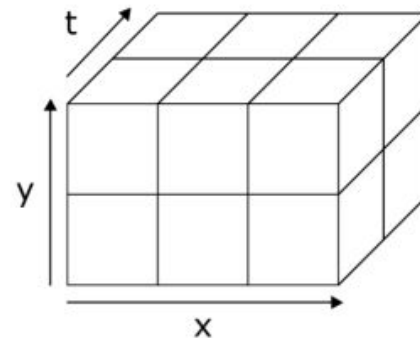
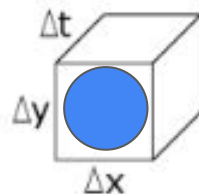
Motivation: Saturation models only exist for short and uniform light pulses...



From Onsemi

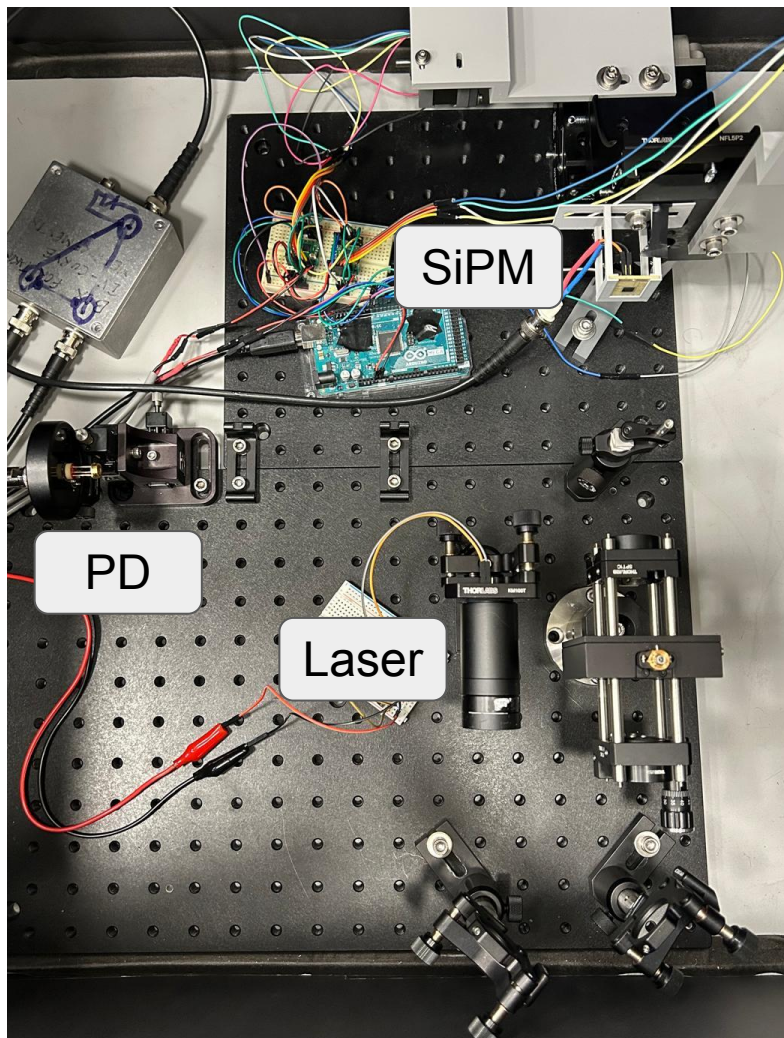
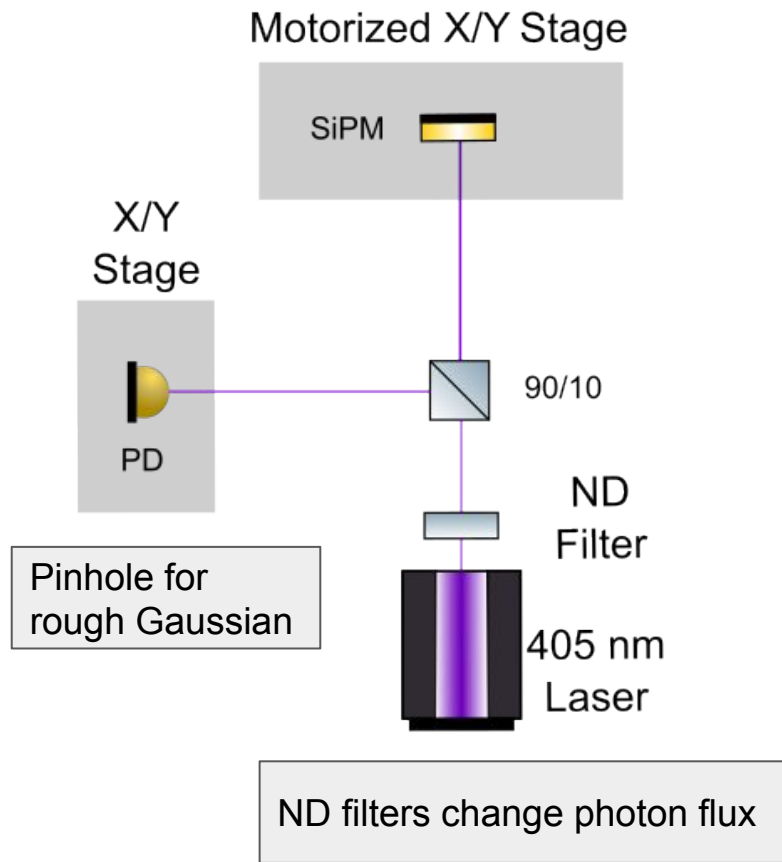


Model



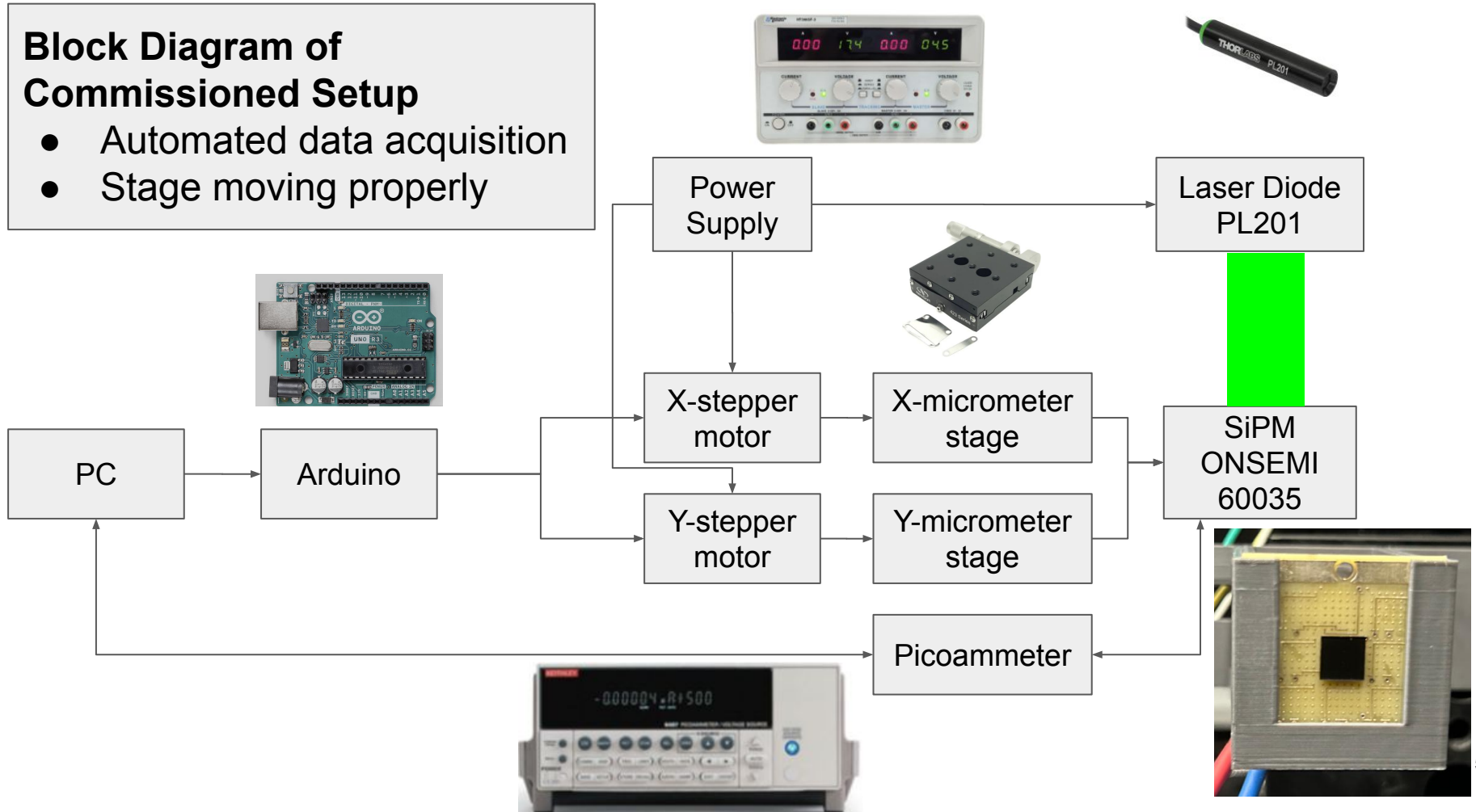
- Characterize the non-linear response of SiPMs to non-uniform light
- Analytic equation for Gaussian profile
- Varying flux of photons
- Simulation shows it should work

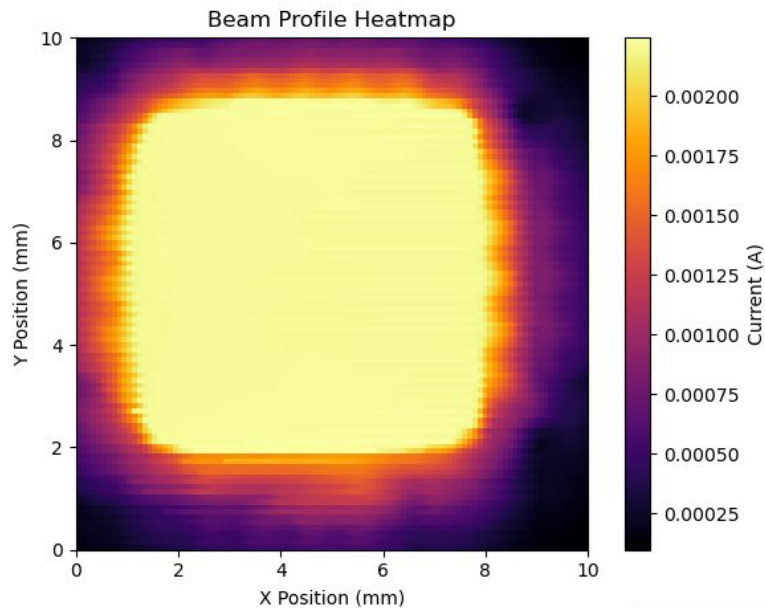
Optical Path



Block Diagram of Commissioned Setup

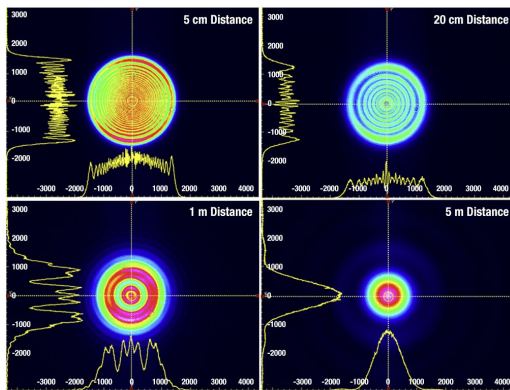
- Automated data acquisition
- Stage moving properly



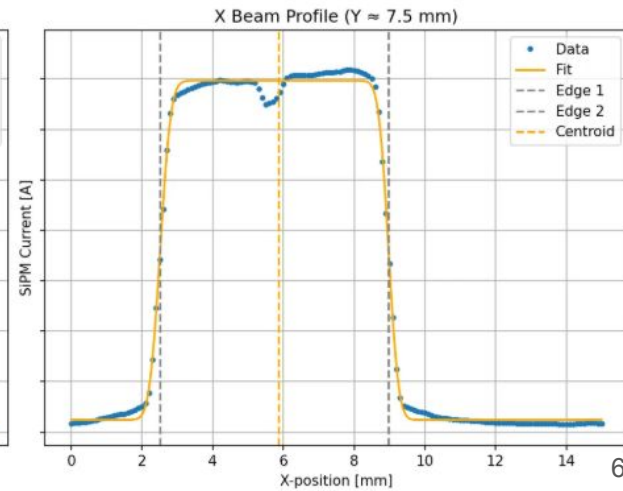
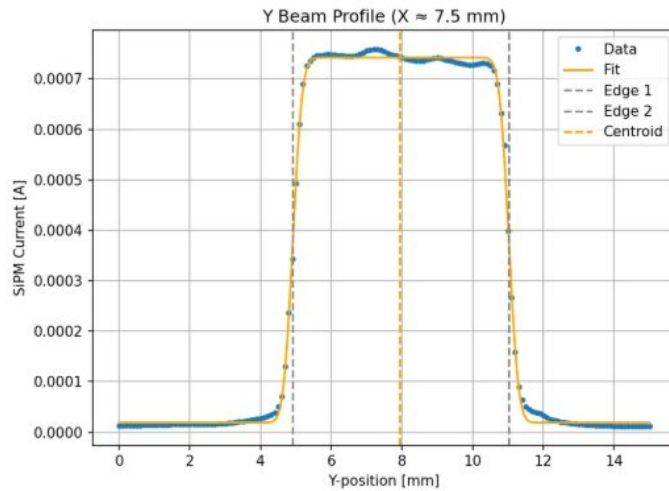


Data for Commissioned Setup

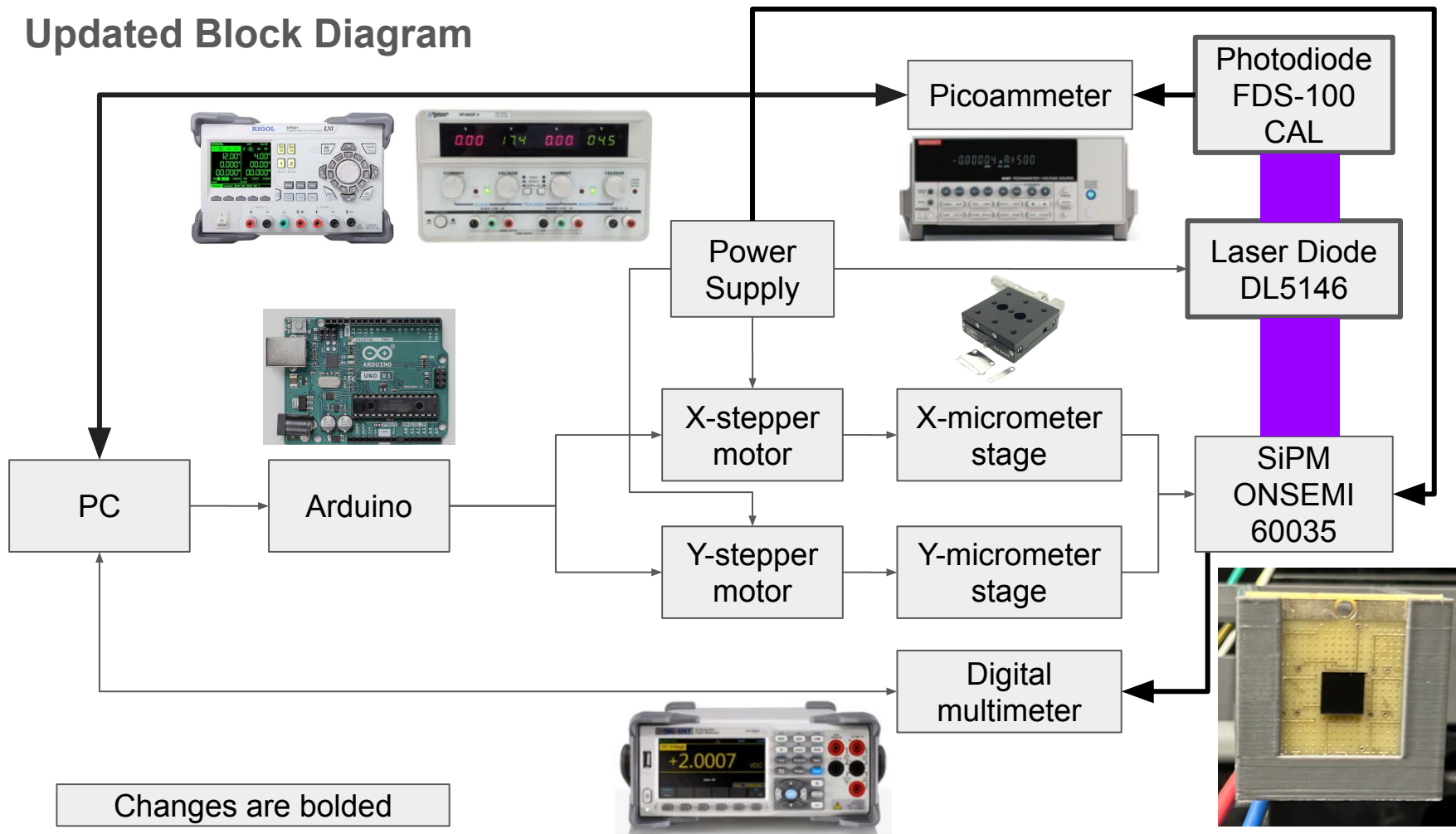
- 2D raster scan of device
- Measurement devices and stage work properly
- 1D line scans used to profile beam
- Integrating top hat beam



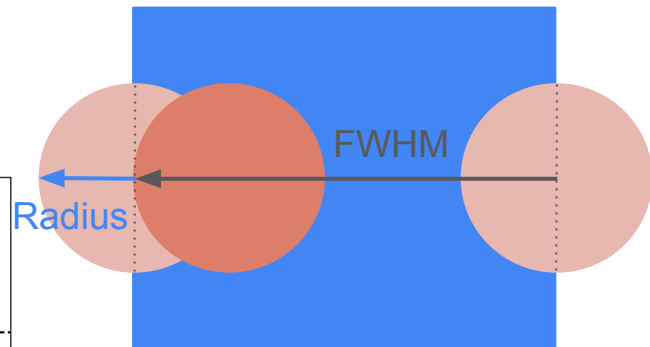
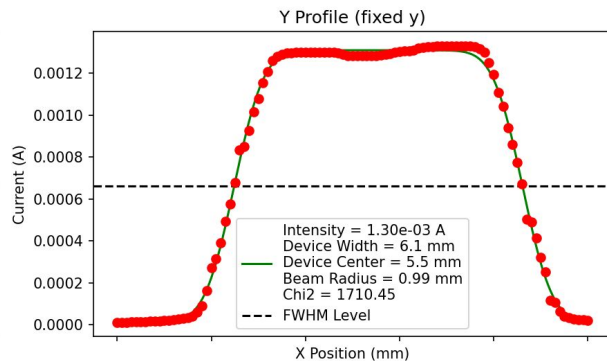
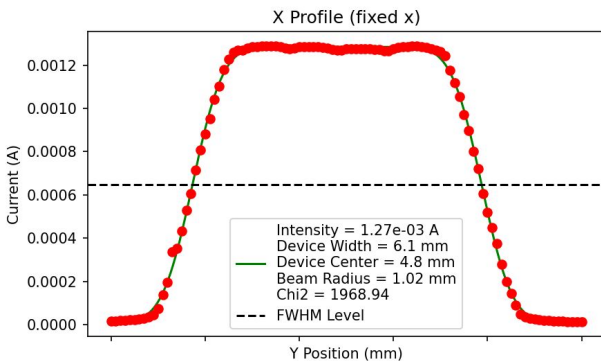
From Thorlabs



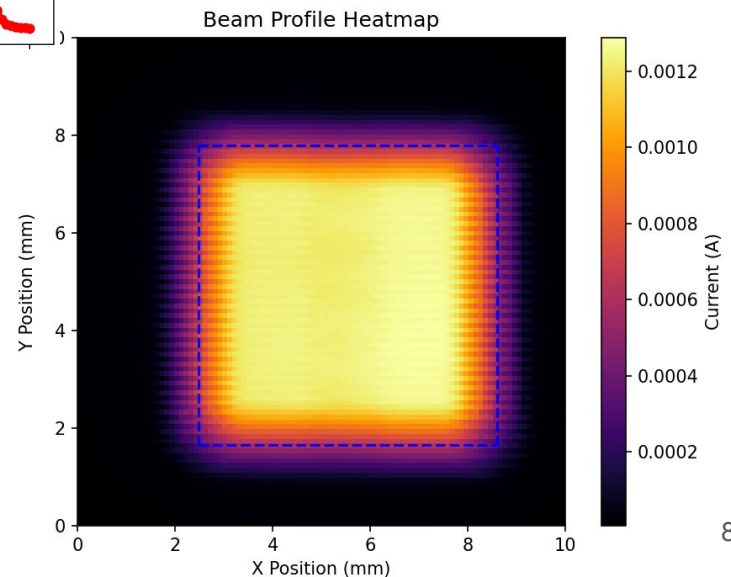
Updated Block Diagram



Final Data



- Profile of beam show a roughly Gaussian beam with ~ 1 mm radius
- Better raster scan with dimension of SiPM outlined in blue: 6.1x6.1 mm
 - FWHM helps to find center

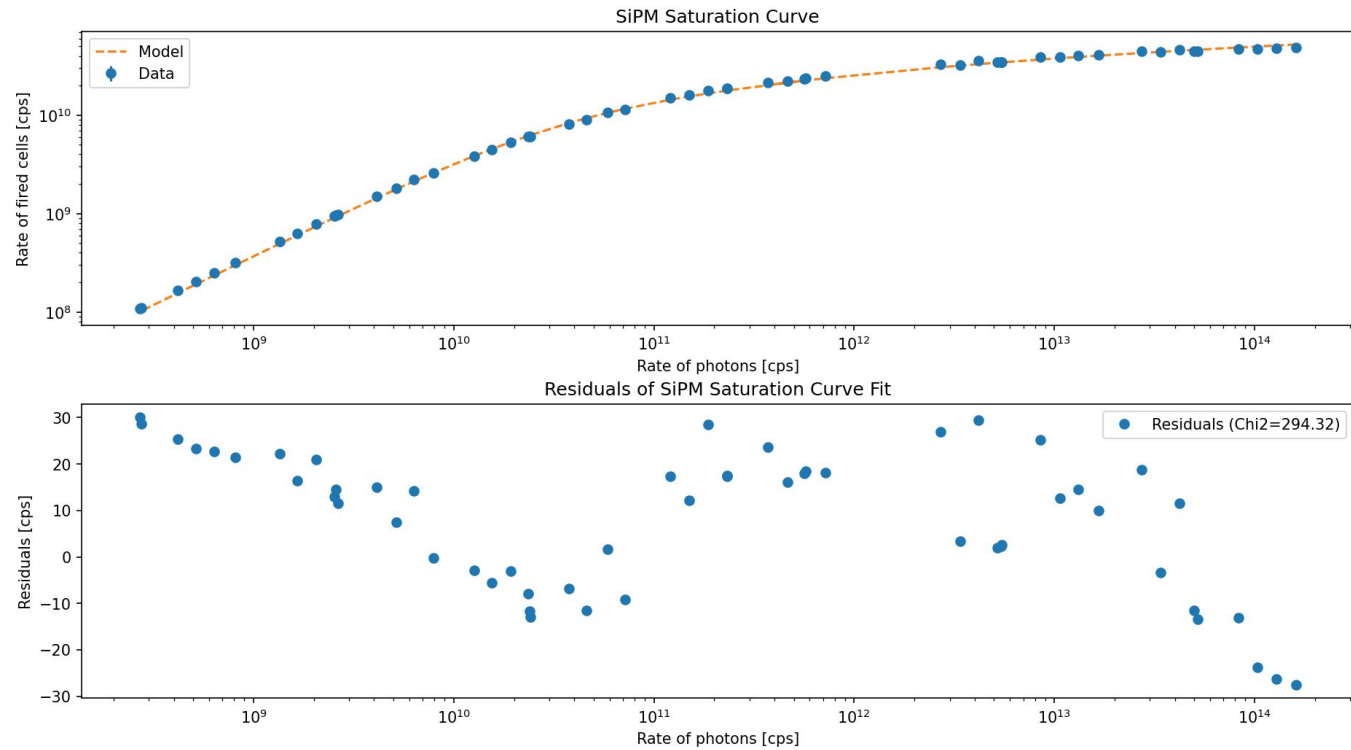


Parameters

Data Sheet: Pixel Size
(Δx , Δy), PDE, Gain,
ECF

Measured Data: Beam
Standard Deviation (σ),
 N_{photons}

Floating: Reset Time
(Δt)



$$\langle R \rangle = \frac{2\pi\sigma_x\sigma_y}{\Delta x\Delta y\Delta t} \left[\gamma + \log \left(\frac{\text{PDE} \times N_{\text{photons}}}{2\pi\sigma_x\sigma_y/\Delta x\Delta y\Delta t} \right) - \text{Ei} \left(\frac{-\text{PDE} \times N_{\text{photons}}}{2\pi\sigma_x\sigma_y/\Delta x\Delta y\Delta t} \right) \right]$$

Summary

I measured the SiPM's saturation response to non-uniform light and it matched the model!

Next Steps

- Spatial filter for cleaner Gaussian
- Test with different voltages
- Write up the findings

Questions?



From Thorlabs website

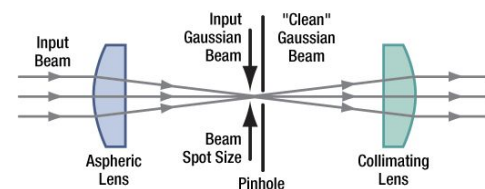


Figure 1.1 Spatial Filter System

Intensity "noise". When a beam is focused by an aspheric lens, the input beam is transformed into a central Gaussian (see Figure 1.2). The radial position of the side fringes is proportional to the spatial frequency of the "noise".

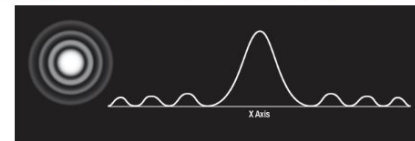


Figure 1.2 Input Gaussian Beam

The "clean" portion of the beam can pass while the "noise" fringes are blocked (see Figure 1.3).

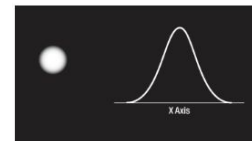
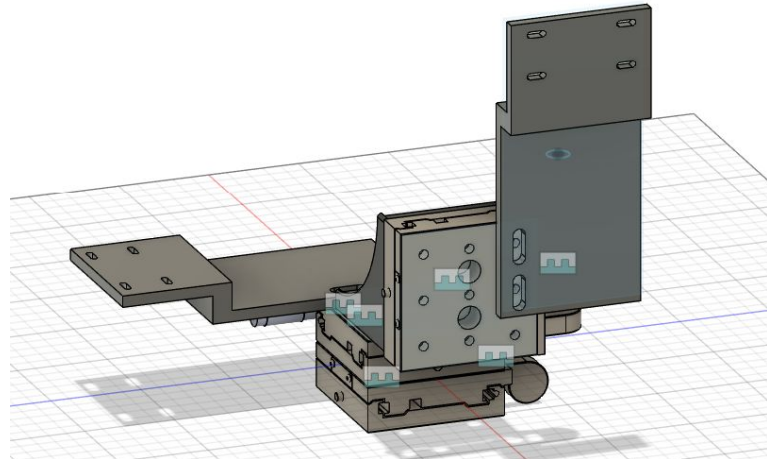
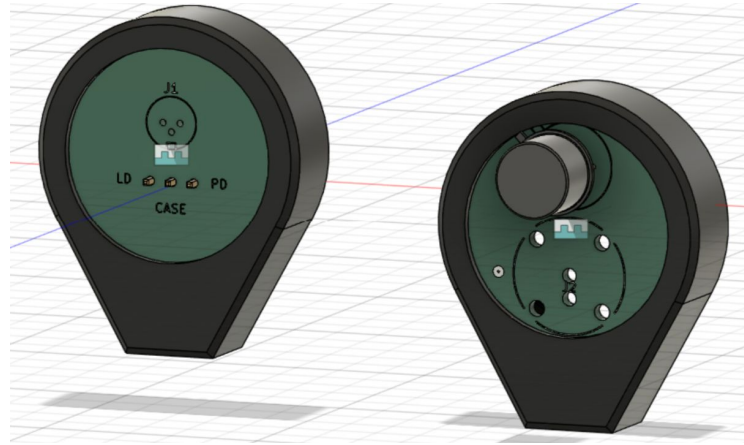
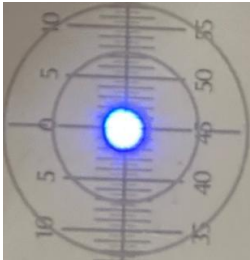
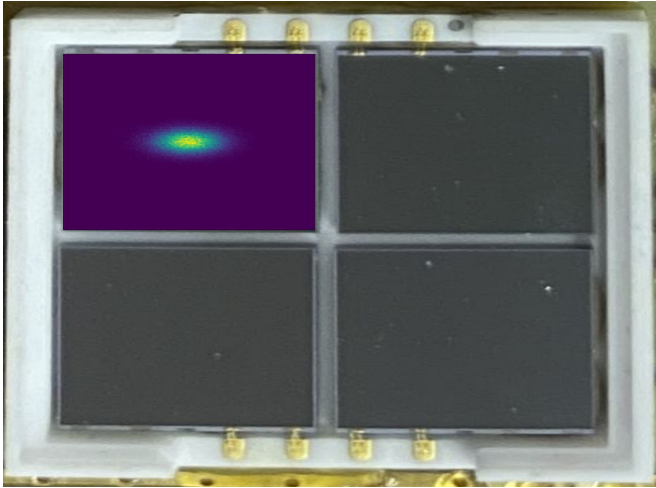


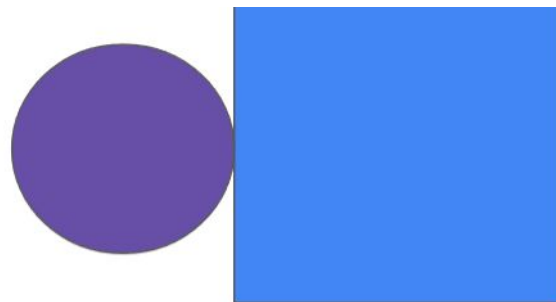
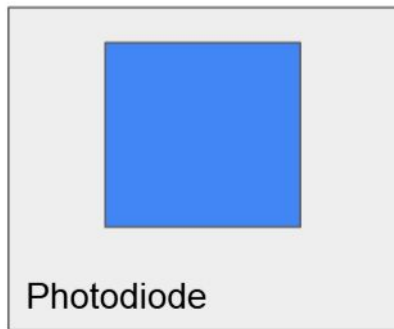
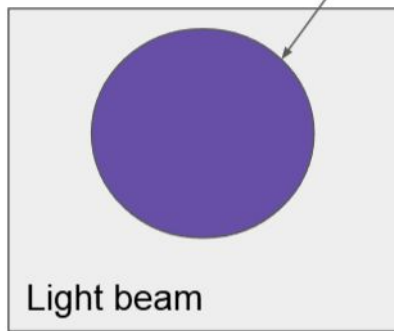
Figure 1.3 Clean Gaussian Beam

Additional Resources



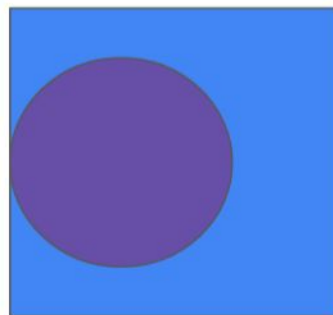
Spot size

P_0/e^2

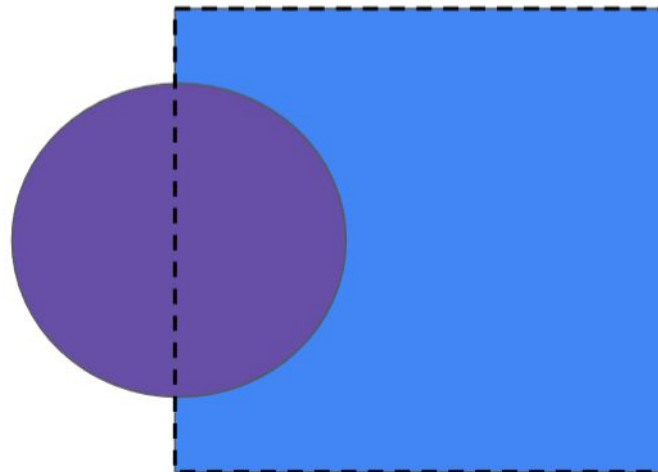


Min signal

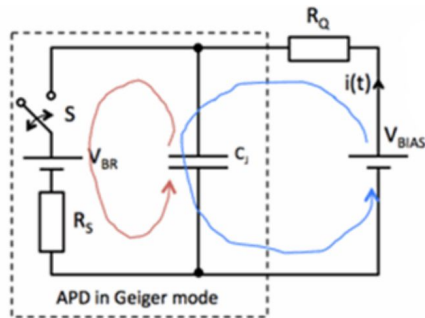
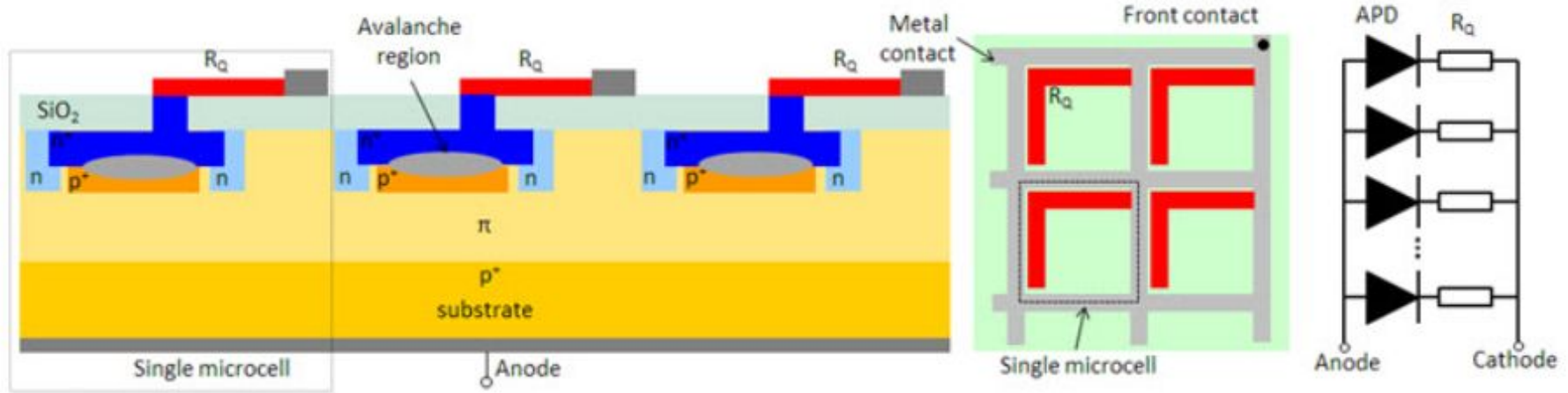
Half max
signal



Max signal

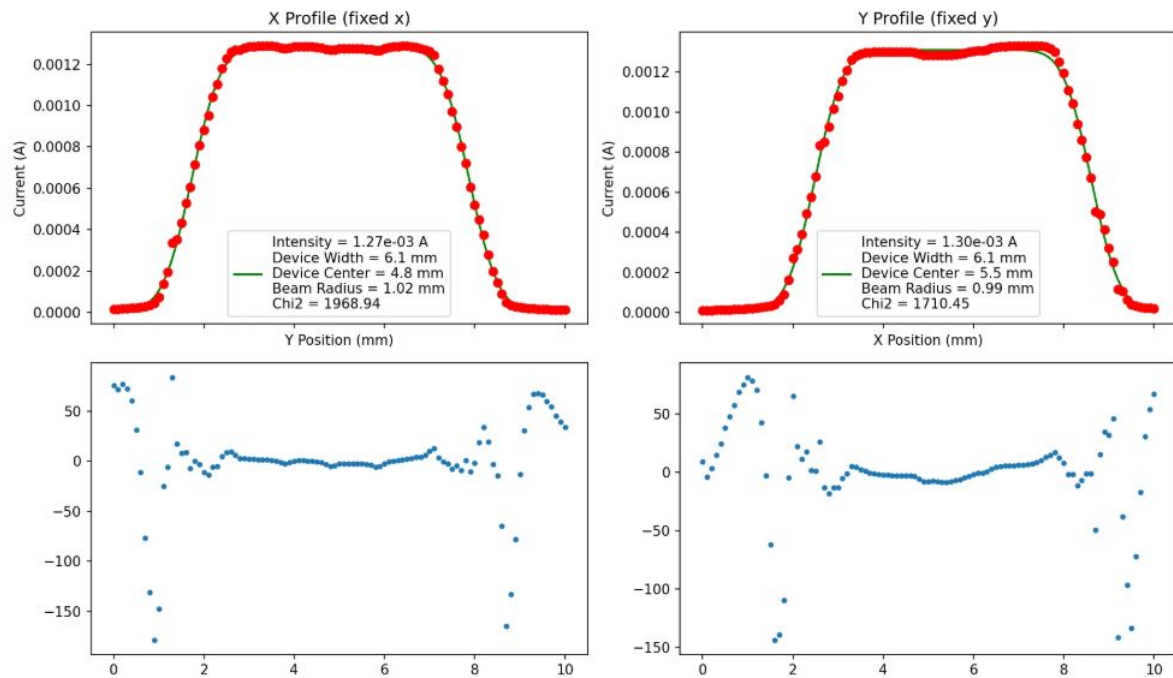


More about SiPMs - All Hamamatsu Images

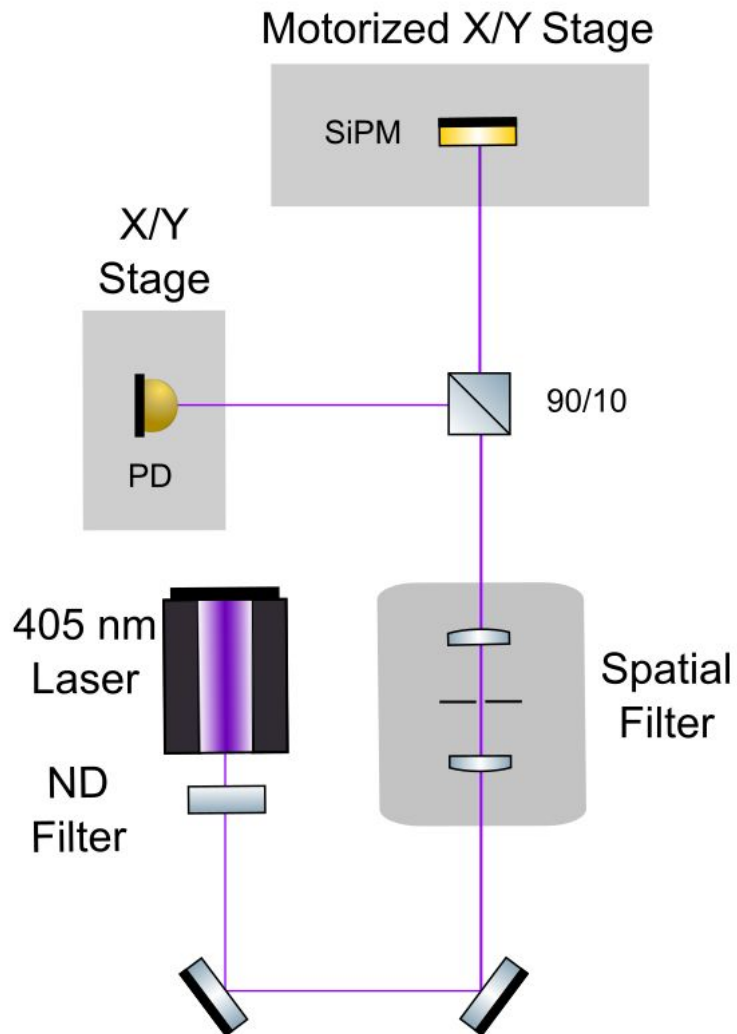


(Recharge) Time Constant = $R_Q C_J$

- Fully recharged after about five time constants



$$I = \langle R \rangle * \text{gain} * \text{ECF}$$



$$\langle N \rangle = \sum_{ijk}^{n_x n_y n_t} (1 - \exp(-PDE_{ij} \cdot U_{ijk}))$$



$$\langle N \rangle = \int \frac{dx \, dy \, dt}{\Delta x \Delta y \Delta t} (1 - \exp(-PDE \cdot \Phi(x, y, t) \Delta x \Delta y \Delta t))$$



$$\langle R \rangle = \frac{2\pi\sigma_x\sigma_y}{\Delta x\Delta y} \left[\gamma + \log \left(\frac{PDE \times N_{photons}}{2\pi\sigma_x\sigma_y/\Delta x\Delta y} \right) - \text{Ei} \left(\frac{-PDE \times N_{photons}}{2\pi\sigma_x\sigma_y/\Delta x\Delta y} \right) \right]$$

Motivation

- Silicon photomultipliers (SiPMs) are solid state photodetectors widely adopted in particle physics experiment
- Many detectors require large arrays of SiPMs
- High-throughput wafer-level testing typical for SiPM mass production
- High-throughput (IV) testing in tension with precision testing (pulse counting)
- Can we extract the same information from pulse counting measurements using IV?
- **Resolving temporal and spatial saturation is the first step required for IV parameter extraction**

Automation IV Probe Station



FormFactor Inc: [SUMMIT200 Probe Station for Automated Wafer Handling - FormFactor](#)

